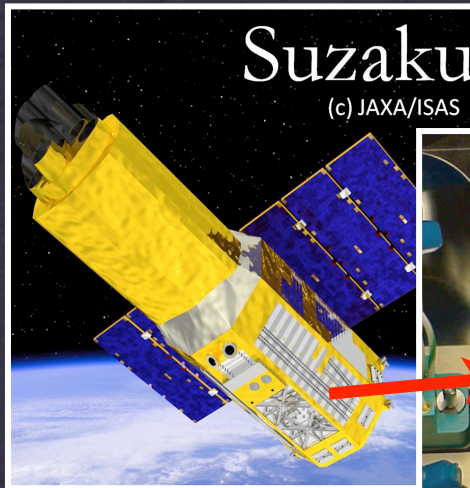


# Development of a Fully Depleted Back Illumination Sensor Based on SOI CMOS Technology for Future X-Ray Astronomy Satellites

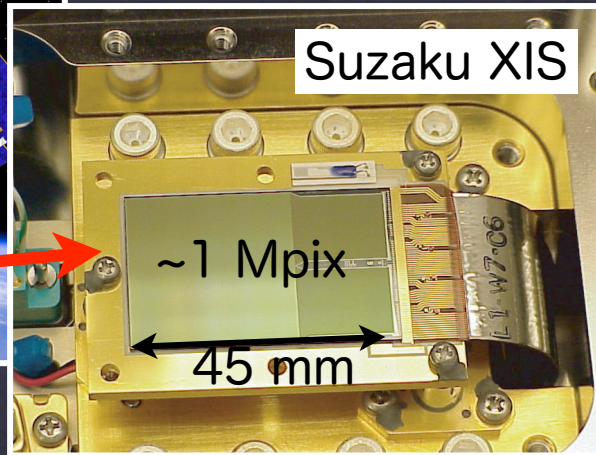
Hideaki Matsumura (Kyoto University)

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A. Takeda, Y. Arai, T. Miyoshi, R. Ichimiya,  
T. Imamura, T. Ohmoto, A. Iwata

# Motivation in X-ray Astronomy



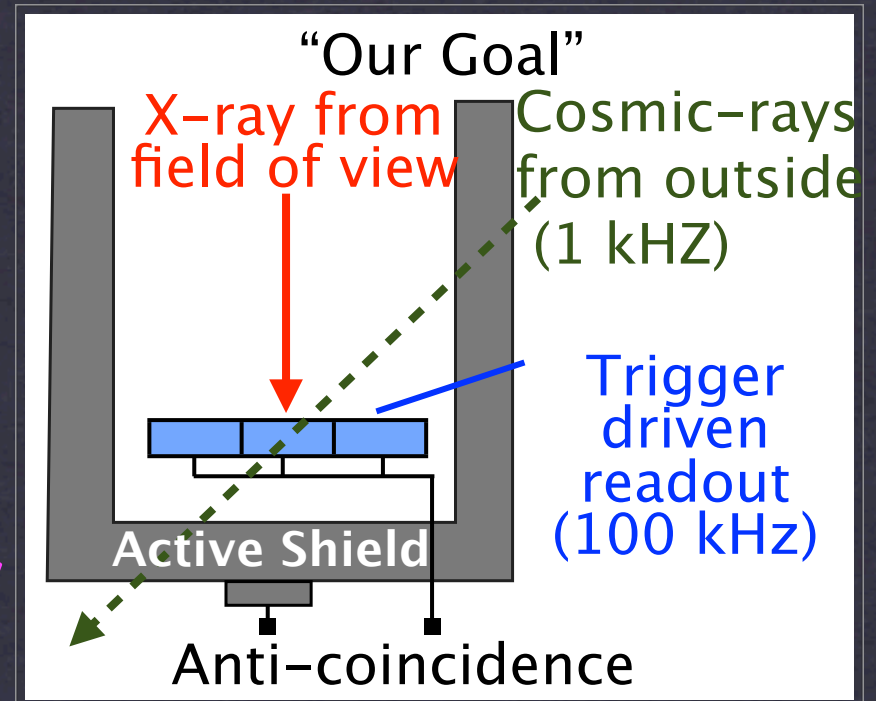
Standard Detector  
= X-ray CCDs



new imaging spectrometer  
capable of high speed readout  
and low background

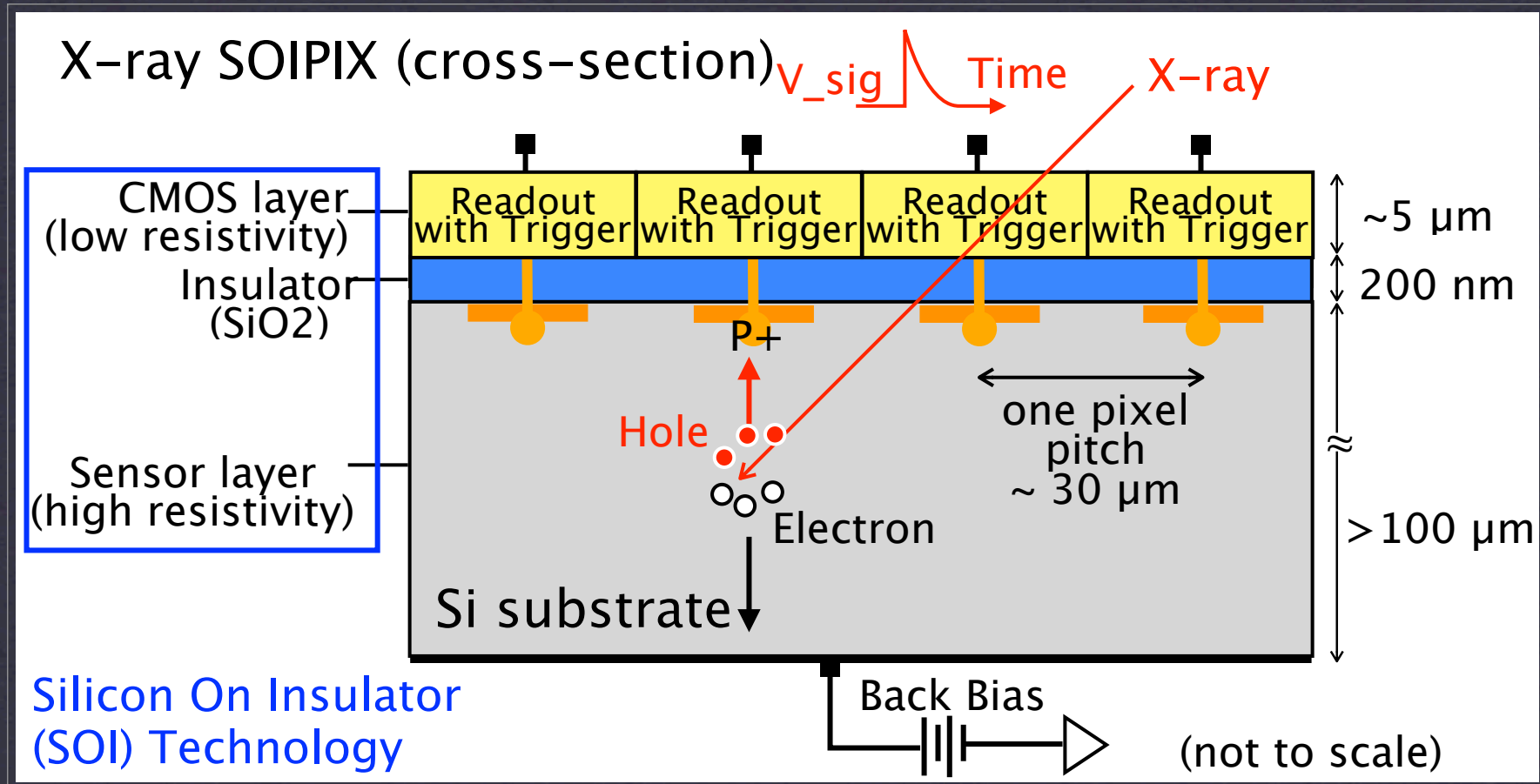
## Weak Points

- Poor time resolution of ~ sec
- Non X-ray background above 10 keV  
- due to cosmic rays in satellite orbit



	positional resolution	Energy resolution	Timing resolution	observable energy band
CCD	~ 20 $\mu\text{m}$	2% FWHM@6 keV	~ sec	0.5 - 10 keV
SOI pixel	< 30 $\mu\text{m}$	2% FWHM@6 keV	< 10 $\mu\text{sec}$	0.5 - 40 keV

# Concept of X-ray SOIPIX



- Monolithic pixel sensor by Silicon on Insulator (SOI) Tech
- Si sensor + CMOS readout circuit with trigger

# Achievements and Scope of This Work

## Achievements

- ▶ Trigger-driven readout of X-ray signals
- ▶ Thick depletion layer (500  $\mu\text{m}$ )
- ▶ Readout noise  $\sim 60 e^-$
- ▶ Energy resolution 700 eV FWHM at 8 keV

## Scope of This Work

- ▶ Spectroscopy with back illumination (BI) device
- ▶ Investigation of charge collection efficiency

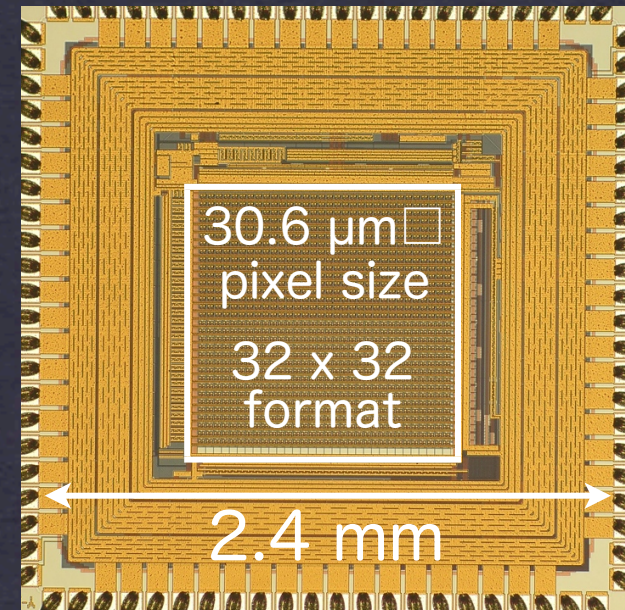
# Prototype: XRPIX1b

## XRPIX1b-CZ-BI:

- Back illumination sensor
- Sensor layer: 100  $\mu\text{m}$
- Resistivity: 0.7  $\text{k}\Omega\text{cm}$

## XRPIX1b-FZ-FI:

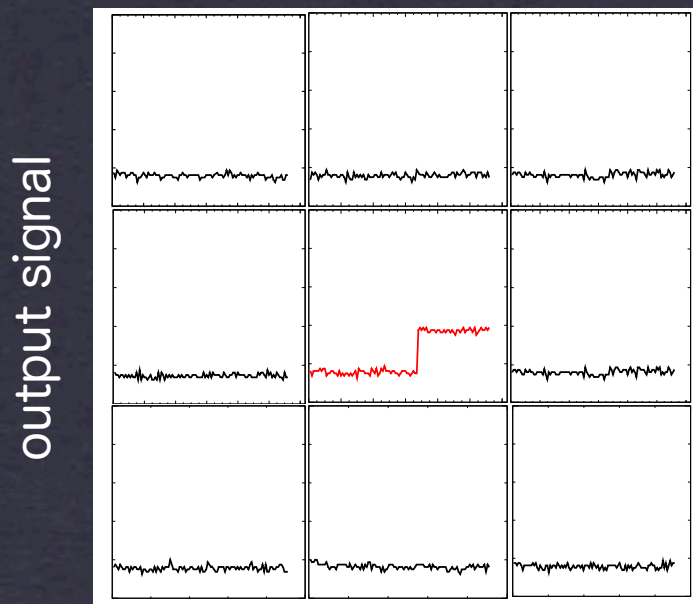
- Front illumination sensor
- Sensor layer: 500  $\mu\text{m}$
- Resistivity: 7  $\text{k}\Omega\text{cm}$



# 3 x 3 Pixel Readout Method

- We used special readout method to reduce readout noise
- Charge often spreads over several pixels

1 pixel event

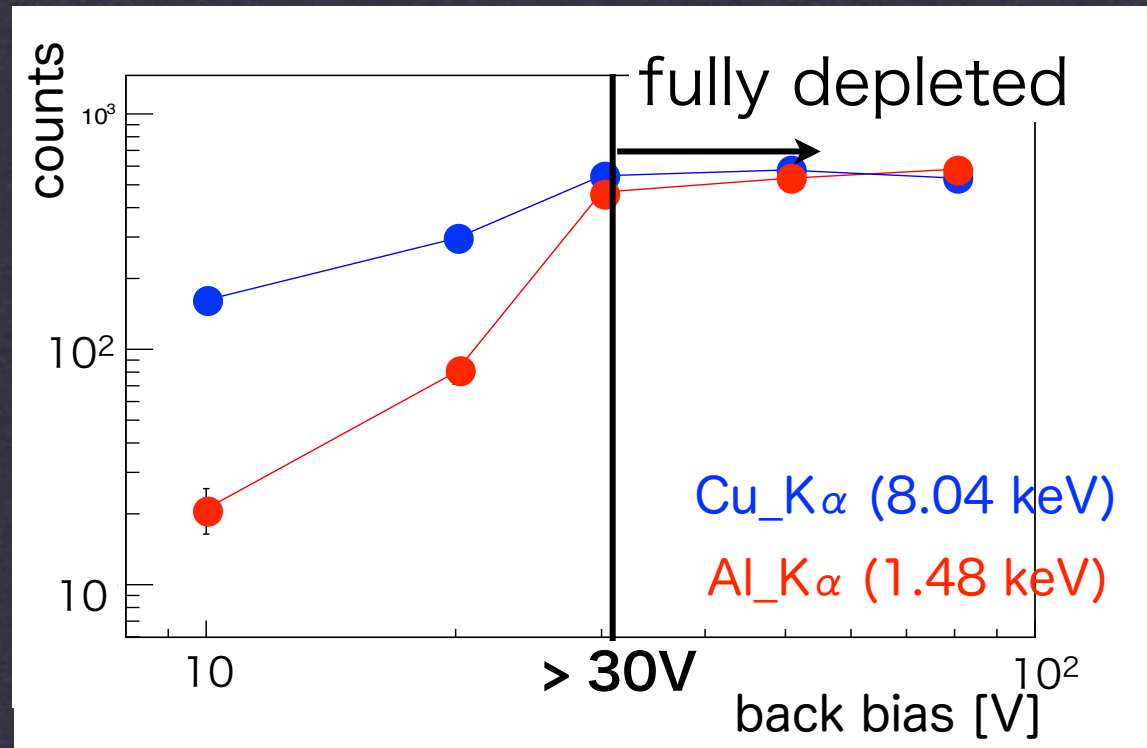
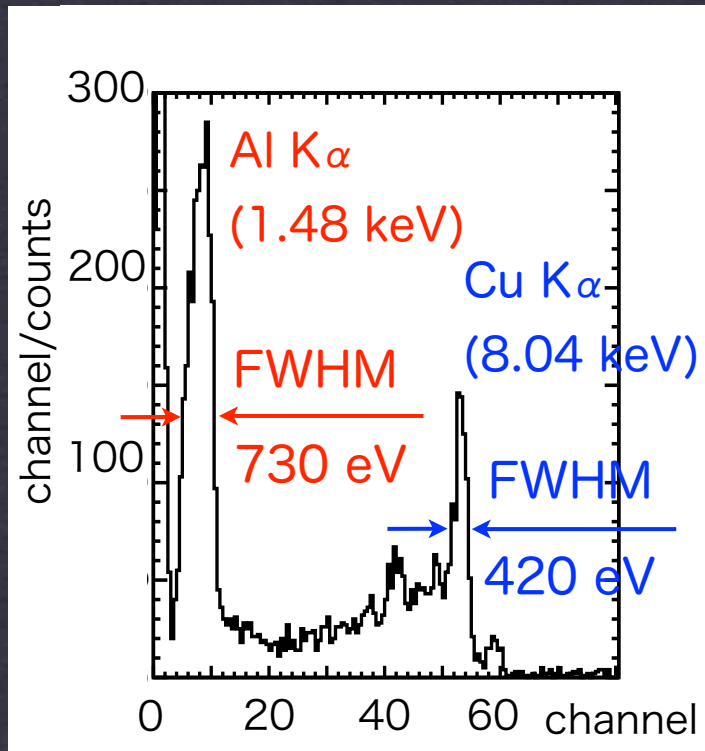


2 pixel event



# BI Spectrum

Device: XRPIX1b-CZ-BI



Back Bias: 85 V

Temperature: - 50 °C

1 hit events spectrum

Quantum Efficiency at 1.48 keV

= 30 %

⇒ dead layer = 9.3  $\mu\text{m}$

# Issues on BI Device

(1) Energy resolution at Al line (1.48 keV)

BI: 730 eV

FI (same device): 300 eV

(2) Thick dead layer

9.3  $\mu\text{m}$   $\gg$  our goal  $\sim$  0.1  $\mu\text{m}$

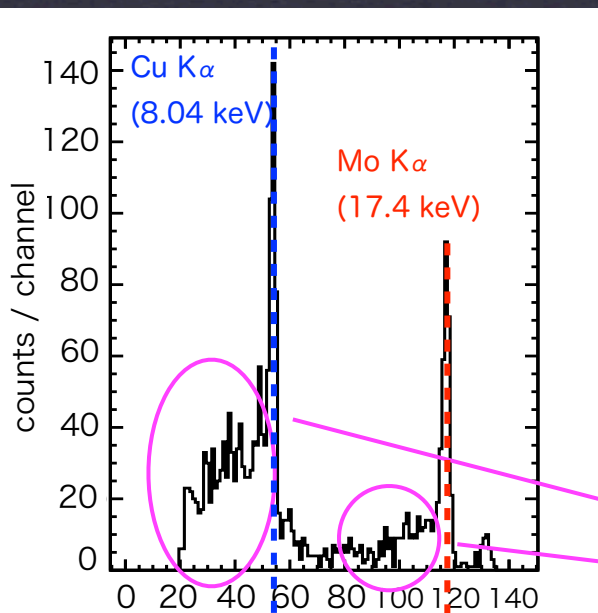
We consider that this degradation is due to imperfection backside process.

Improvement of backside treatment is ongoing.



# Spectral Shape

1 pixel event



Device: XRPIX1b-FZ-FI

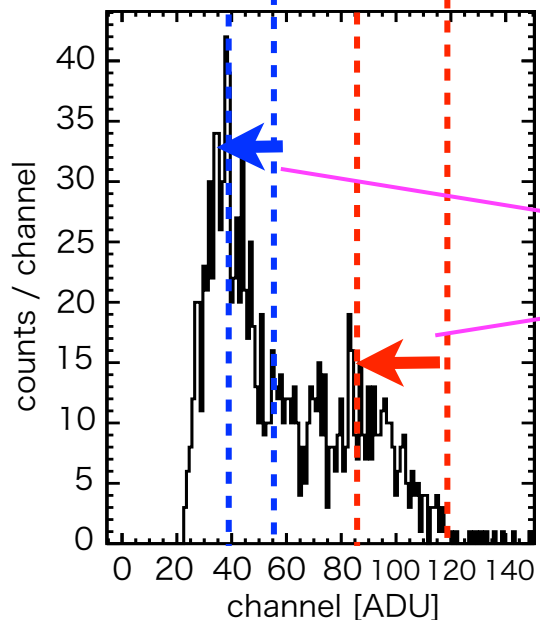
Back Bias: 30 V

Temperature: - 50 °C

1 pixel and 2 pixel events spectrum

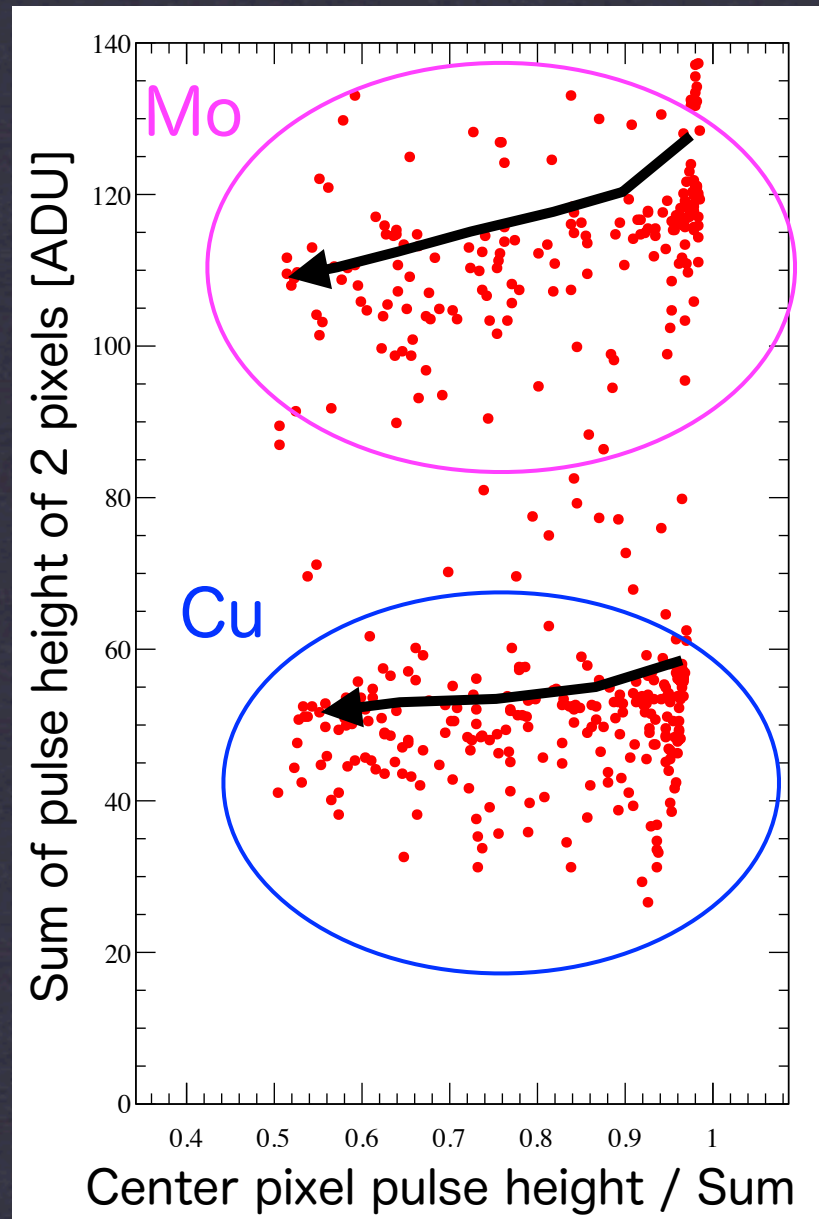
Large tail components

2 pixel event



Peak shift

# Spectral Shape

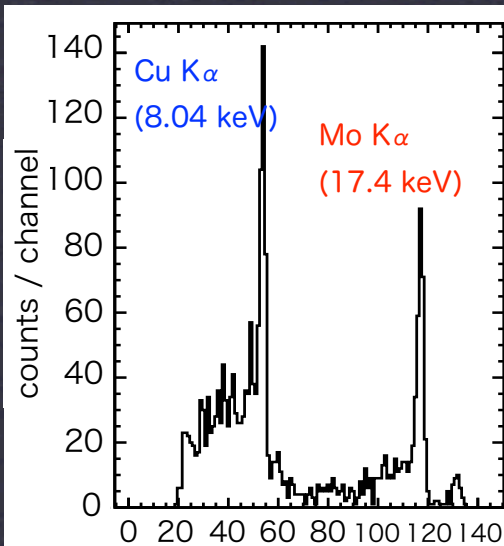


# Comparison with Previous Device

Current Device  
XRPIX1b-FZ-FI

BPW size  
small

1 pixel  
event

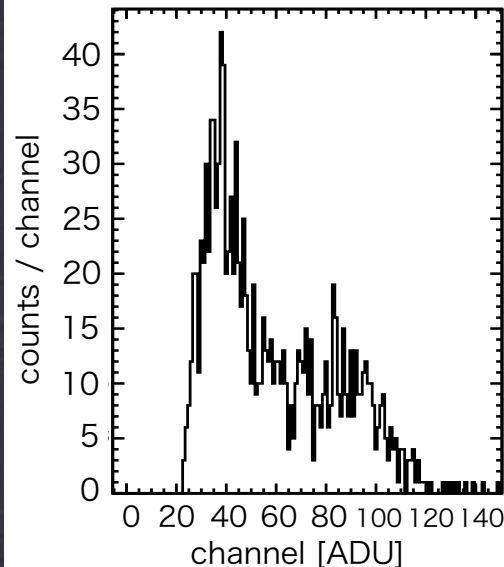


1 pixel  
event

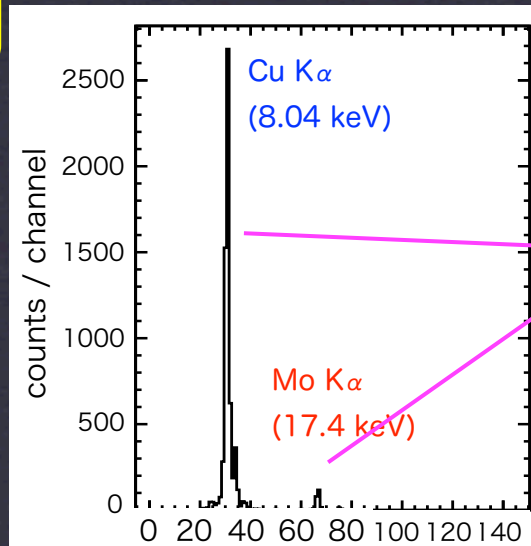
Previous Device  
XRPIX1-FZ-FI

BPW size  
large

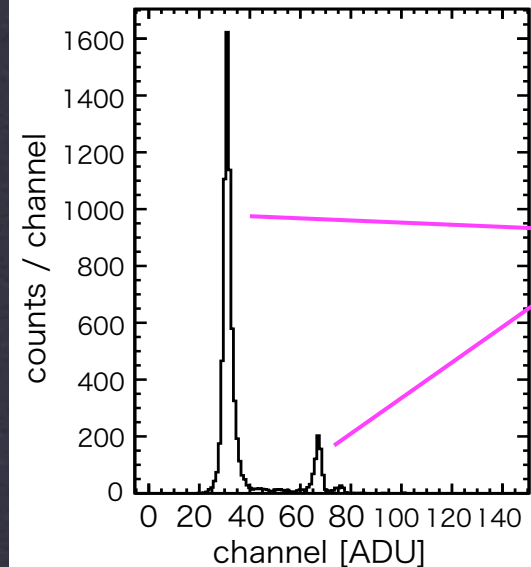
2 pixel  
event



2 pixel  
event



No tail

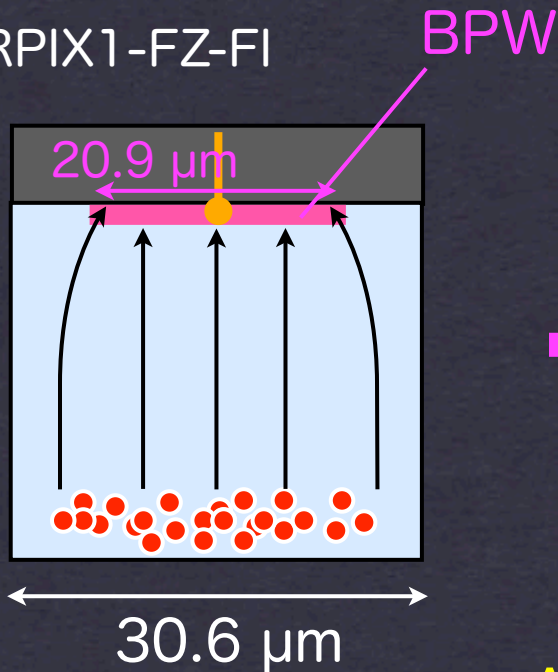


No peak  
shift

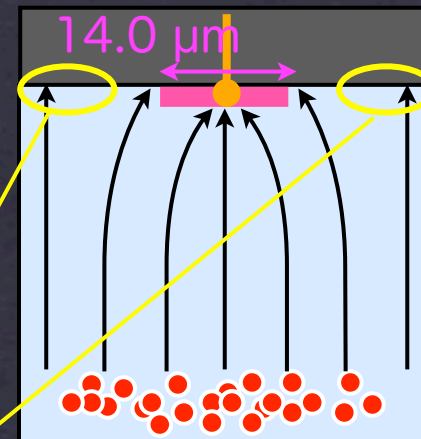
# Our Hypothesis of Charge Loss

Buried P-Well (BPW): Suppression of backgate effect

Previous Device  
XRPIX1-FZ-FI



Current Device  
XRPIX1b-FZ-FI



A part of signal charge is lost at the interface region between the insulator and the sensor layer

⇒ We plan to test the hypothesis by irradiating the device with a pencil X-ray beam

# Summary

- ▶ We successfully obtained spectrum of Al lines using Back Illumination SOPIX for the first time.
- ▶ Energy resolution is 730 eV for Al line (1.48 keV).
- ▶ We think that a part of signal charge is lost at the interface region between the insulator and the sensor layer.
- ▶ We can test our hypothesis with a pencil beam experiment.

**Thank You**